# **Materials Science and Engineering Department, NIT Calicut**

### **DC SPUTTERING**

## **Photo of Instrument:**



Instrument Name	DC SPUTTERING			
Instrument Model & Serial No.	MAGNETRON SPUTTERING UNIT,			
	D1027			
Instrument Make	HIND HIGH VACUUM			
<b>Category of Instrument</b>	Sample preparation			
<b>Description of Instrument</b>				
<b>Instrument Technical Description and</b>	1.Metals, Metal oxide and Ceramics coating			
Major Specifications (This Specifications	2.Two-inch Target			
Limited to Major 5)	3.CO-sputtering			
Application of Instrument (Limited to	1.Coating (Thin Films)			
Major 4 or 5)	2.Semiconductor Industries			
	3.Biological / Polymer sample coating			
Type of Sample Required for Analysis /	1.Glass slide / Silicon water (max dimension -			
Testing (Quantity, Pre-Preparation, State etc.)	75mm×25mm-2nos)			

## **Materials Science and Engineering Department, NIT Calicut**

Guidelines for Sample Submission –	2.Standerd cleaning procedure for Glass slide
<b>User Instructions</b>	
Types of Analysis / Testing	
Faculty In-Charge Name / Email /	Dr. Soney Varghese
	soneyva@nitc.ac.in
Contact	
Technical Staff Name / Email / Contact	
<b>Location of Instrument</b>	Functional Material Laboratory
Other Details	

### **User Charges**

S.NO.	Type of Analysis/Testing	Internal - within Departme nt of NITC	Internal - Other Department s NITC	External Academic Educational Institutes	National Labs	Industry
1	1.Coating (Thin					
	Films)					
	2.Semiconductor					
	Industries					
	3.Biological /		200/hour	500/hour+	500/hour	1000/hour+
	Polymer sample		+Target	Target	+ Target	Target
	coating		charges	charges	charges	charges

#### **Slot Booking and Payment Work Flow:**

Contact the Faculty In-charge and Technical Staff through ema